## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of		)	
ANATOLY FABRIKANT ET AL.		, )	
For:	IMPROVED SYSTEM FOR SCATTEROMETRIC MEASUREMENTS AND APPLICATIONS	) ) ) )	San Francisco, California
_		/	San Francisco, Camfornia

Patent Application **Assistant Commissioner for Patents** Washington, D.C. 20231

By Express Mail No: EL492667862US

Dated: September 27, 2000

## PATENT APPLICATION TRANSMITTAL

Sir:

Transmitted herewith for filing is the patent application of inventors ANATOLY FABRIKANT, GUOHENG ZHAO, DANIEL C. WACK and MEHRDAD NIKOONAHAD, for "IMPROVED SYSTEM FOR SCATTEROMETRIC MEASUREMENTS AND APPLICATIONS." Enclosed are:

- 1. Fifty (50) pages of the specification, including one-hundred fifteen (115) claims and an abstract.
- 2. Fourteen (14) sheets of drawings.

The filing fee will be deferred at this time.

Dated: September 27, 2000.

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